Electronic Patent Application Fee Transmittal							
Application Number:	10	10792038					
Filing Date:	03	03-Mar-2004					
Title of Invention:	Co	Composition and process for post-etch removal of photoresist and/or sacrificial anti-reflective material deposited on a substrate					
First Named Inventor/Applicant Name:	Me	Melissa K. Rath					
Filer:	Tri	Tristan Anne Fuierer					
Attorney Docket Number:	АТ	ATMI-668					
Filed as Large Entity							
Utility under 35 USC 111(a) Filing Fees							
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:							
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Filing a brief in support of an appeal		1402	1	540	540		
Post-Allowance-and-Post-Issuance:							
Fytension-of-Time:							

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
	Total in USD (\$)			540